

Search Notes 	Application No. 10/612,977	Applicant(s) LEE, JAE GU
	Examiner (Nancy) Thanh-Nhan P Nguyen	Art Unit 2871

SEARCH NOTES (INCLUDING SEARCH STRATEGY)		
	DATE	EXMR
349/39.ccls. 349/38,39.ccls. and exposure 349/38,39.ccls. and ((halftone adj mask) (diffractive adj mask) (slit adj mask))	9/29/2004	TN
438/30.ccls. and capacitor\$ 438/30.ccls. and (partial with exposure)	9/30/2004	TN
438/30.ccls. and ((halftone adj mask) (diffractive adj mask) (slit adj mask))	9/30/2004	TN